



PATENT APPLICATION

Date September 17, 2003

In re the Application of

Masaru MITSUI et al.

Group Art Unit: 1752

Application No.: 09/509,472

Examiner: Y. Thornton

Filed: April 21, 2000

Docket No.: 105875

For: PHOTOMASK BLANK, PHOTOMASK, METHODS OF MANUFACTURING THE SAME
AND METHOD OF FORMING MICROPATTERN

RECEIVED
SEP 23 2003
TC 1700

**LARGE ENTITY PETITION FOR 1st - 3rd EXTENSION
OF TIME UNDER 37 C.F.R. §1.136(a) AND
TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired June 17, 2003, an extension of time for a period of three months is hereby requested. Attached hereto is our Check No. 146422 in the amount of \$930 in payment for:

- Extension fee for response within first month pursuant to §1.136(a) (\$110.00)
 Extension fee for response within second month pursuant to §1.136(a) (\$410.00)
 X Extension fee for response within third month pursuant to §1.136(a) (\$930.00)

The Commissioner is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461. Two copies of this petition are enclosed.

Respectfully submitted,

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JAO:JSA:CWB/rav

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**DEPOSIT ACCOUNT USE
AUTHORIZATION**
Please grant any extension
necessary for entry;
Charge any fee due to our
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